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A.P. MAHOROWALA
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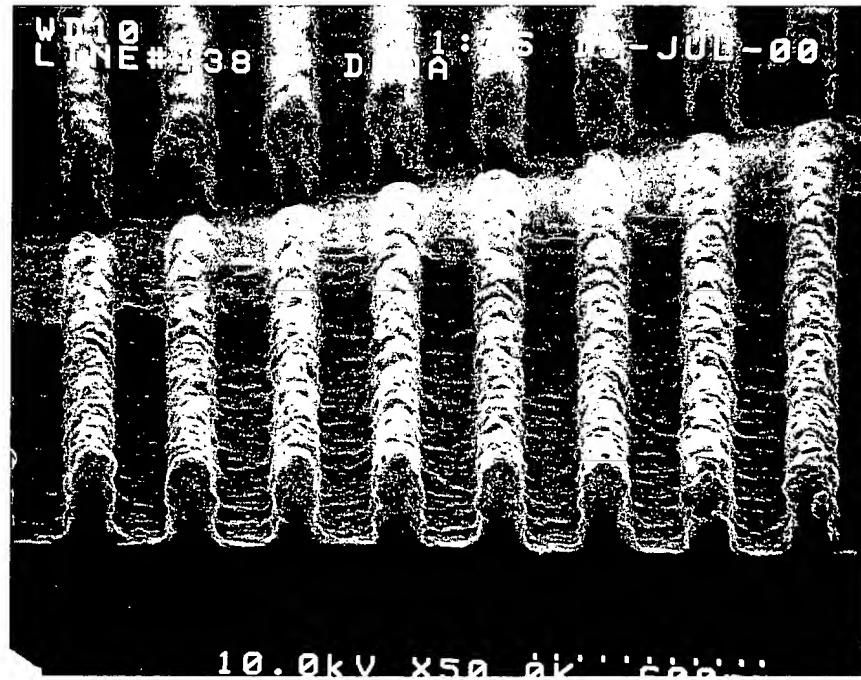
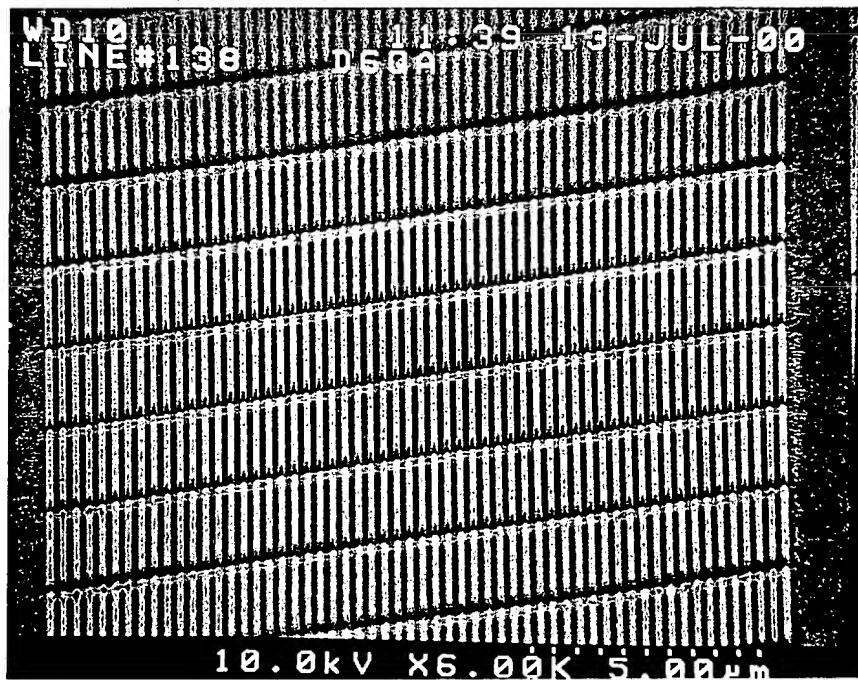


FIG.1A



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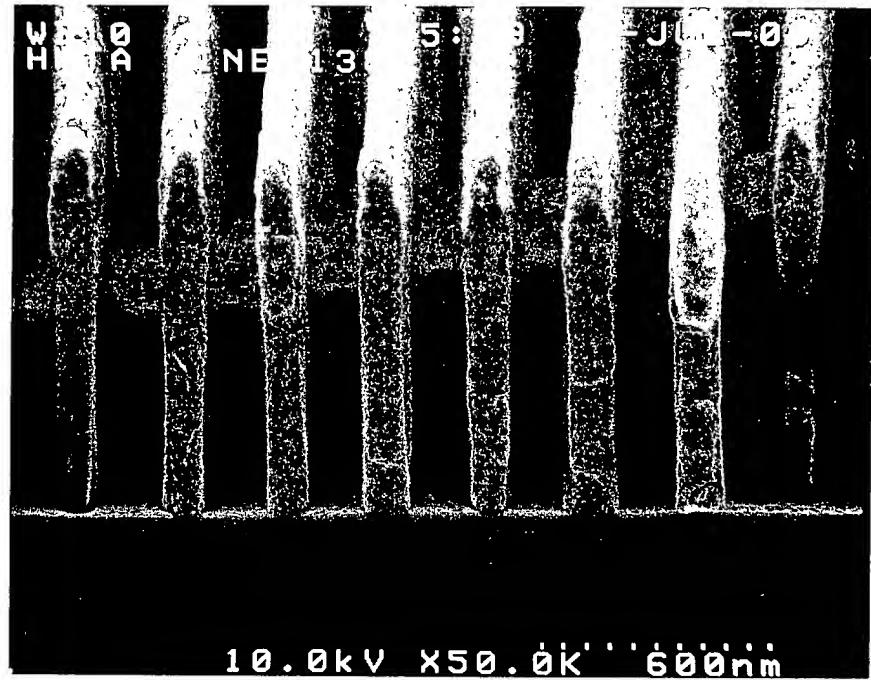
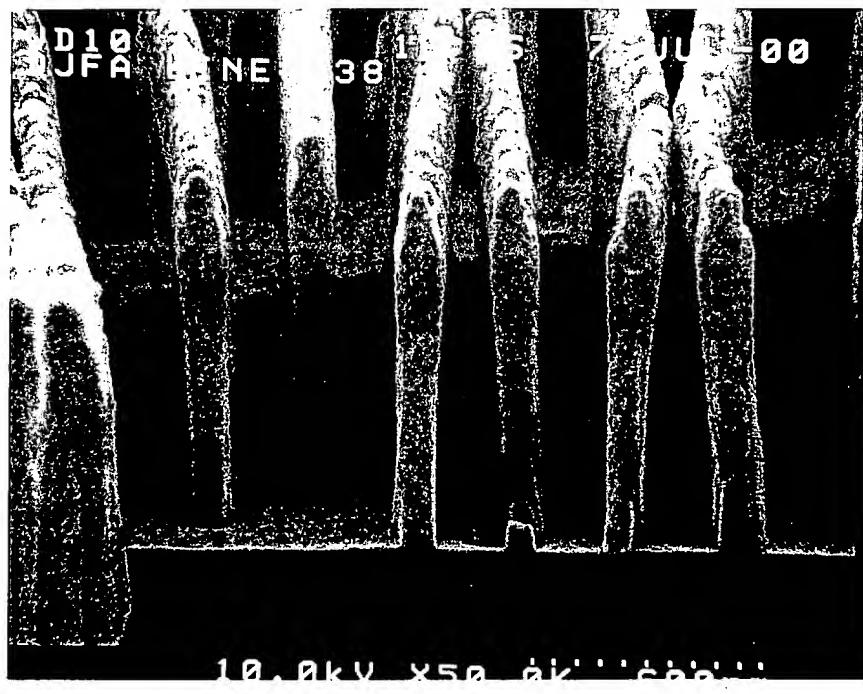


FIG. 2A



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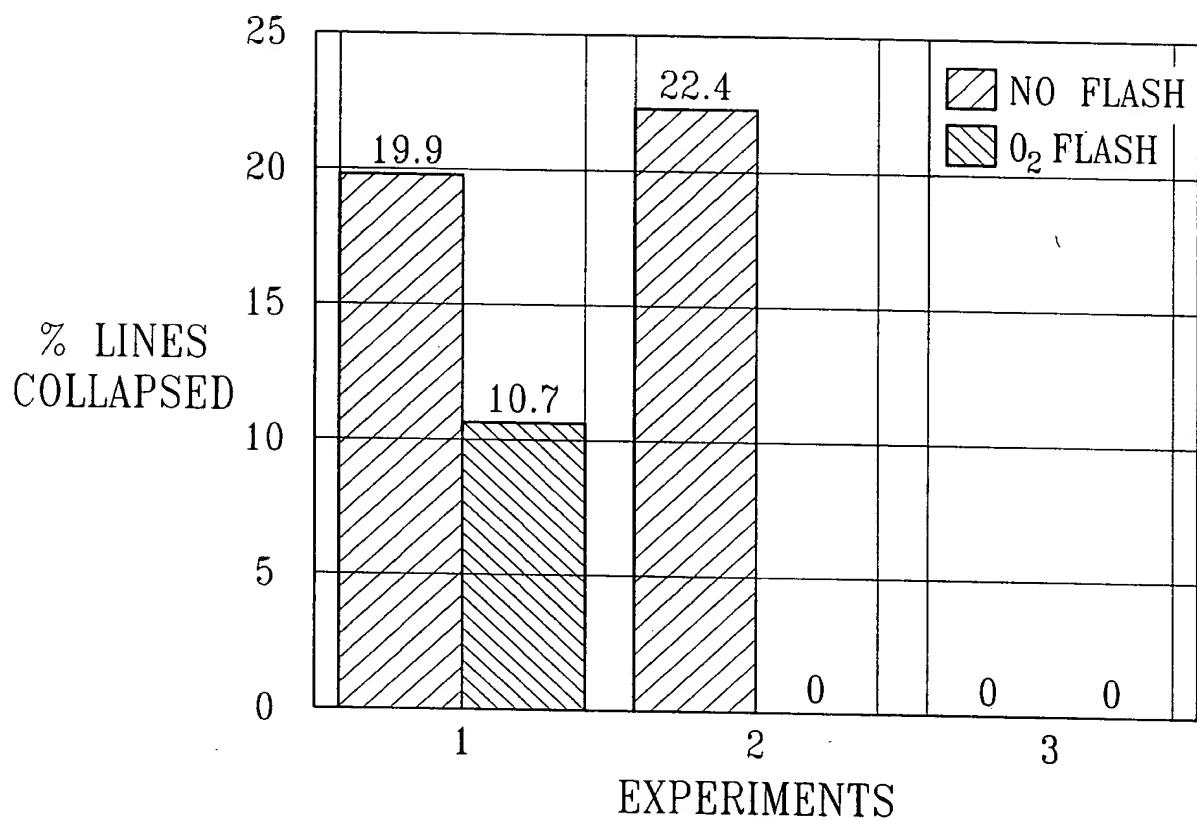


FIG. 3

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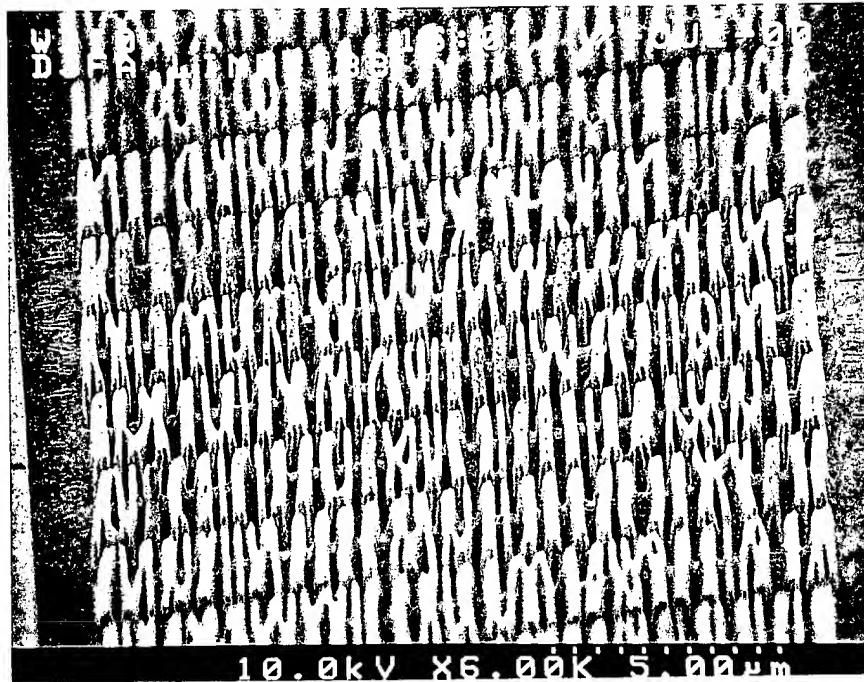
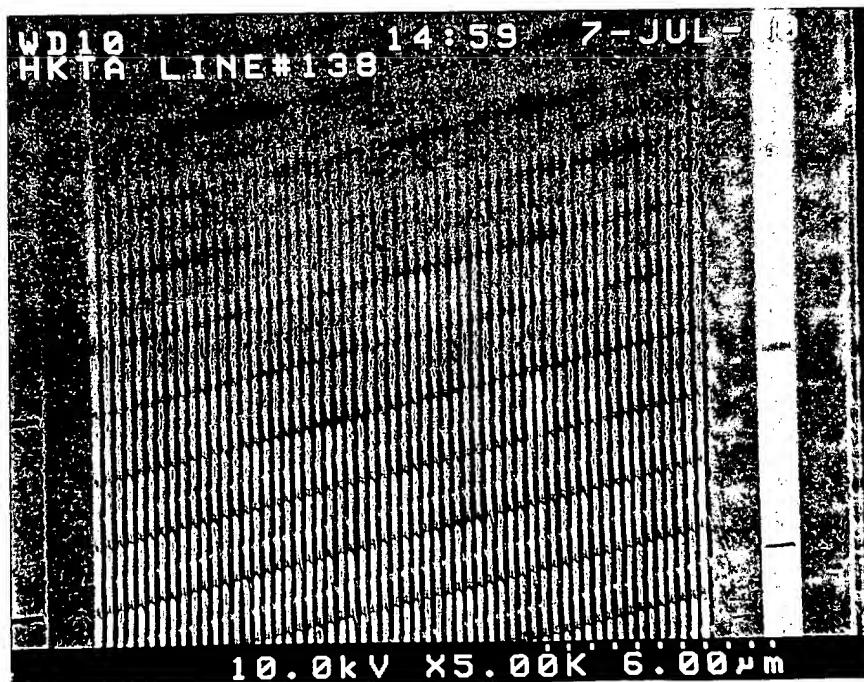


FIG. 4A





1756

Docket No.: 20140-00272-US
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE #3

In re Patent Application of:
Arpan P. Mahorowala

Conf. No.: 9522

Application No.: 09/902,728

Group Art Unit: N/A

Filed: July 12, 2001

Examiner: Not Yet Assigned

For: METHOD TO PREVENT PATTERN
COLLAPSE IN FEATURES ETCHED IN
SULFER DIOXIDE-CONTAINING PLASMAS

SUBMISSION OF FORMAL DRAWINGS

Commissioner for Patents
Washington, DC 20231

Dear Sir:

Applicants submit herewith 4 sheets of formal drawings of Figs. 1A-1B, 2A-2B, 3 and 4A-4B.

Dated: October 18, 2002

Respectfully submitted,

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